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32	Solid polymer derived from ethylenic reactants only	61	With nitrogen-containing additive DNRM
33	Solid polymer or SICP derived from at least one aldehyde or aldehyde derivative reactant	62	With hydrocarbon DNRM additive which is nonresinous and which is nonbituminous, or noncoal derived, e.g., cutback
34	Paper plant solid waste material or cotton, e.g.,		asphalt, kerosene, paraffin wax, etc.
	white liquor, etc.	63	Coke additive
35	Cellulose	64	Asphaltene or maltene
36	Sulfur-containing ester,		additive
	e.g., viscose, xanthate, etc.	65	Coal derived additive, e.g.,
37	Carboxylic acid ester		lignite, etc.
38	Mixed carboxylate ester	66	Tar or pitch
39	Acetate	67	Oil shale
40	At least one solid polymer derived from ethylenic reactants only	68	Two or more solid polymers, or graft or graft-type, or block or block-type solid
41	Acetate	C 0	copolymer
42	<pre>Ether group containing, other than solely linking carbohydrate groups directly to each other</pre>	69	Solid polymer derived from ethylenic reactants only at least one of which contains a carboxylic acid or derivative
43	Hydroxyalkyl	70	Solid polymer derived from
44			ethylenic reactants only, at
45	Carboxyalkyl or alkali metal salt thereof		least one of which is propylene
46	Alkyl	71	Solid polymer derived from
47	Starch or derivative or farinaceous meal or flour		ethylenic reactants only, at least one of which is a
48	Dextrin or derivative		hydrocarbon other than
49	Aldehyde reaction product	70	ethylene
50	Ether group, other than solely linking of carbohydrate	72	Lignin or tannin or derivative DNRM
	groups directly to each other	73	Reaction product of lignin or
51	Ester		tannin or derivative with an
52	Solid polymer derived from		oxygen or nitrogen-containing organic reactant
гэ	ethylenic reactants only	74	Solid polymer or specified
53	<pre>At least one carboxylic acid ester</pre>		intermediate condensation product derived from a
54	Dextran or derivative		phenolic compound
55	Gum or derivative	75	Solid polymer contains
56	Disaccharide or	7.5	halogen
	<pre>trisaccharide, e.g., sucrose, etc.</pre>	76	Solid polymer derived from
57	Ester		ethylenically unsaturated
58	Monosaccharide, e.g.,	77	hydrocarbon only
	glucose, fructose, etc.	77	Natural resin or modified
59	Coal, bituminous additive, extract, or derivative thereof; or oil shale; or fatty still residue DNRM		forms thereof other than rosin or its modified forms DNRM, e.g., shellac, dammar, etc.
60	\ldots With water additive DNRM		

78	Residue of undetermined constitution derived from	98	Nitrogen ring having at
	destructive distillation of a	99	least seven ring membersSix-membered nitrogen ring,
	plant or animal source or		e.g., pyridine, etc.
	plant or animal extract of undetermined constitution DNRM	100	Six-membered nitrogen ring
79	DNRM is derived from pyrolysis		having two or more ring
19	of previously formed solid	1.01	nitrogen atoms
	synthetic polymer	101	Three oxygen atoms are
80	DNRM which is other than		directly bonded to three nuclear carbon atoms of the
	silicon dioxide, glass,		nitrogen ring, e.g., (iso)
	titanium dioxide, water,		cyanurate, etc.
	halohydrocarbon, hydrocarbon,	102	Two or more nitrogen rings
	or elemental carbon	103	Nonhetero nitrogen
81	Organic DNRM	104	Five-membered nitrogen ring
82	Sulfur atom as part of a	105	Two or more nitrogen rings
	hetero ring DNRM	106	Five-membered nitrogen
83	Hetero ring contains sulfur	100	ring having two or more ring
	and at least one diverse		nitrogen atoms
	hetero atom	107	At least one chalcogen atom
84	Five-membered sulfur ring	_0,	as part of a hetero ring
85	Three-membered sulfur ring		(chalcogen=O, Se, Te) DNRM
86	Nitrogen atom as part of a	108	Two or more chalcogen atoms
	hetero ring DNRM		in the same hetero ring
87	Nitrogen ring directly	109	Two or more chalcogen rings
	fused or bridged to a ring	110	Six-membered chalcogen ring
	system	111	Five-membered chalcogen
88	Tetrabenzoporphyrazine		ring
	nucleus containing, e.g.,	112	Cyclic polycarboxylic acid
	phthalocyanine, etc.		anhydride
89	Nitrogen ring is part of a	113	Tetrahydrofuran per se
	ring system having three or	114	Three-membered chalcogen
	more rings fused or bridged		ring
0.0	together	115	Phosphorus organic compound
90	Nitrogen ring is part of		DNRM
	a ring system having five or	116	Phosphorus is part of a
	more rings fused or bridged		covalent ring
91	together	117	Oxygen ring atom
91	Three or more nitrogen atoms in the fused or bridged	118	Halogen
	ring system	119	Two or more phosphorus
92	Two nitrogen atoms in the		rings
22	fused or bridged ring system	120	Spiro ring
93	1,3-diazole	121	Two or more phosphorus
94	Five-membered nitrogen		atoms directly or indirectly
7 1	containing ring		bonded together by only
95	At least one diverse hetero		covalent bonds
73	atom in same ring	122	Phosphorus double bonded
96	Six-membered nitrogen ring		to an atom other than C or O
2 0	having at least one diverse	123	Phosphorus bonded directly
	hetero atom, e.g., morpholine,		to three chalcogen atoms and
	etc.		having only one P-C linkage,
97	Two or more nitrogen	104	e.g., phosphonate, etc.
	rings	124	Nitrogen
	-	125	Aryl group

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126	Phosphorus bonded directly to only two chalcogen atoms	153	Triphenyl phosphite per se
	and having at least one P-C linkage, e.g., phosphinate,	154	Phosphorus directly bonded
			to carbon atoms only
	phosphonite, etc.	155	Organic compound having a
127	Phosphorus bonded directly		sulfur bonded directly to
	to four chalcogen atoms, e.g.,		oxygen DNRM
		156	
	phosphate, etc.	156	Sulfur bonded directly to
128	Phosphorus bonded directly		four oxygen atoms
	to three chalcogen atoms only,	157	Sulfur bonded directly to
	e.g., phosphite, etc.	137	
100			three oxygen atoms
129	Phosphorus directly bonded	158	Aryl group
	to at least one chalcogen and	159	Nitrogen
	only H or C, e.g., phosphine	160	Fused or bridged ring
	oxide, etc.	100	
130			system
130	Phosphorus bonded to three	161	Metal
	chalcogen atoms and having	162	At least two separate
	only one P-C linkage		aryl groups
131	Chalcogen other than		
1 31		163	Halogen
	directly bonded to P	164	
132	Aryl group	165	Halogen
133	Phosphorus bonded to only	166	_
	two chalcogen atoms and having		Metal
		167	Sulfur bonded directly to
	at least one P-C linkage		two oxygen atoms, e.g.,
134	Sulfur		sulfones, etc.
135	Aryl group	168	
136	Pentavalent phosphorus atom	100	Sulfur bonded directly to
130			nitrogen
	directly bonded to at least	169	Aryl group which is not
	one oxygen atom		fused or bridged
137	P directly bonded to S	170	_
138	P directly bonded to two	170	Aryl group
130	-	171	Oxygen atom other than as
	or more N		part of a sulfur bonded
139	Phosphorus directly bonded		directly to two oxygen atoms
	to at least one O and at least	170	
	one H or C only	172	\ldots Atom other than C, H, S,
1.40			O, or metal
140	P directly bonded to	173	Sulfur directly bonded to
	oxygen only		oxygen and devoid of an aryl
141	Aryl group		
142			group, e.g., dimethyl
	Halogen		sulfoxide, etc.
143	Cresyl phosphate, e.g.,	174	Organic compound having at
	di, etc.		least one metal atom directly
144	Halogen		
145			bonded to a carbon or hydrogen
143	C-O-P-O-C, or C-O-P-OH		atom DNRM
	group, e.g., phosphate ester,	175	Heavy metal directly bonded
	lecithin, etc.		to carbon or hydrogen atom
146	Phosphorus directly bonded	176	
	to sulfur	170	Transition metal (at. no.
			21-29, 39-47, 57-79)
147	Phosphorus directly bonded	177	Group VA metal (Sb, Bi,
	to oxygen		As)
148	Atom other than C, O, H,	178	,
			Tin atom
	P, or Hal	179	At least one sulfur atom
149	Halogen	180	Sulfur directly bonded
150	Five or more aryl groups		to tin
151	Two or more aryl groups	101	
		181	With additional tin
152	OH group		compound DNRM

182 183 184	At least two tin atomsBoron organic compound DNRMAtom other than B, O, H, or C	213	Atom other than C, N, H, or chalcogen; or contains nitrogen or chalcogen atom other than as part of a N(C=X)
185	Atom is N	214	Carbocyclic group
186	Organo nitrogen compound	215	With water NRM
	other than unsubstituted ammonium salt as sole nitrogen atom DNRM	216	At least one solid polymer derived from ethylenic reactants only
187	Contains rosin or derivative DNRM	217	N atom other than as part of a N-C=X group
188	Silicon atom	218	C=X group other than as
189	Nitrogen to nitrogen bond		part of a N-C=X group
190	N=N group	219	(C=X)X group
191	X=C-N group wherein X is a	220	C-0-C group
	chalcogen	221	C-OH group
192	Two or more N-N bonds	222	Aryl-OH group
193	Aryl-OH	223	Two or more N-C=X groups
194		223	or two or more C-OH groups
195	-	224	At least one solid
193	<pre>N=C=N or N=C-N- group, e.g., carbodiimide , isourea, etc.</pre>	221	polymer derived from ethylenic reactants only
196	N=C=X group wherein X is a	225	Atom other than N, C, H,
	chalcogen, e.g., isocyanate,		or oxygen
	etc.	226	Carbocyclic group
197	At least one solid polymer	227	Two or more N-C=O groups
	derived from ethylenic	228	At least one solid
198	reactants onlyN-(C=0)-O-, e.g., urethane,		polymer derived from ethylenic reactants only
100	carbamate, etc.	229	At least one solid
199	Oxygen other than as part	227	polymer derived from acyclic
	of a N-(C=O)-O- group		monoethylenic hydrocarbon reactant
200	Atom other than N, H, C,	230	
0.01	or 0	230	N-(C=0)alkyl wherein alkyl
201	<pre>N(C=X)X wherein X is a chalcogen, e.g.,</pre>		group contains eight or more carbon atoms
	thiocarbamate, etc.	231	Two or more organo N-C=O
202	Metal or ammonium group		compounds DNRM or with
203	With chalcogen nonreactive organic compound		nonreactant organo nitrogen compound DNRM
204	Heavy metal or aluminum	232	At least one solid
205	Nitrile group		polymer derived from ethylenic
206	Nitrogen atom other than		hydrocarbon reactants only
	as part of a nitrile group	233	Dialkyl amides, e.g.,
207	Atom other than C, H, or		dimethyl formamide, dimethyl acetamide, etc.
208	Atom other than C, H, or N	234	Two or more N-C nitrogen
209	Two or more nitrile groups		nonreactant materials or with
210	N-C=X group wherein X is a		an organo oxygen or nitrogen-
	chalcogen		containing nonreactant
211	N-(C=X)N, e.g., urea, etc.	235	At least one solid
212	Two or more -N-(C=X)N groups		polymer derived from nitrile- containing ethylenic reactant

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236	Trivalent or tetravalent	267	\ldots Two or more Si atoms and at
	nitrogen atom other than		least one Si-C or Si-H group
	unsubstituted ammonium	268	Silicon containing SICP or
237	\ldots Carbon bonded to three N		solid polymer
	atoms, $-C=NH$, or $C=N-C$ group	269	Solid polymer derived from
238	\dots (C=X)X group wherein X is		ethylenic reactants only
	chalcogen	270	Rosin or tall oil or
239	Two or more (C=X)X groups		modified forms thereof as
240	Aryl group		DNRM, e.g., colophony, abietic
241	C=X group where X is		acid, ester gum, etc.
	chalcogen	271	Two or more solid polymers
242	Two or more C=X groups		or at least one solid polymer
243	C-O-C group		and at least one specified
244			intermediate condensation
245	Two or more C-OH groups		product
246	Aryl group	272	Solid polymer derived from
247	C-OH group		at least one ethylenic
248	Aryl-OH group		compound containing a
249	Two or more nitrogen		carboxylic acid or derivative
	atoms or two or more C-OH	273	Solid polymer contains
	groups		halogen
250	Four or more C-OH groups	274	Solid polymer derived from
251	N, C, and H atoms only		ethylenically unsaturated
252	Two or more nitrogen		hydrocarbon only
	atoms	275	Oxygen wax DNRM
253	With water NRM	276	With water NRM
254	Aryl	277	Carnauba wax, beeswax,
255	Two or more separate		montan wax, or oxidized
	aryl ring systems		microcrystalline wax or
256	At least one aryl ring		modified forms thereof
	which is part of a fused or	278	Solid polymer contains
	bridged ring system		halogen
257	Aryl	279	Solid polymer contains
258	Two or more separate		nitrogen
	aryl ring systems	280	\dots X(C=X)X wherein X is
259	Nitrogen as part of a nitro		chalcogen DNRM, e.g.,
	group		carbonate, etc.
260	Nitro compound has an atom	281	Aryl group
	other than C, H, N, or O or has	282	\dots C(C=X)X wherein at least one
	an oxygen or nitrogen atom		X is a chalcogen other than
	other than as part of a nitro		oxygen DNRM
	group	283	Oxygen atom which is not
261	Organic silicon compound		part of the -C(C=X)X group
	having at least one oxygen	284	Carboxylic acid or
	atom DNRM		derivative and wherein the
262	Atom other than Si, O, C,		derivative is other than a
	or H	005	metal salt DNRM
263	Halogen	285	Cycloaliphatic group or
264	Ethylenic group		bridged or fused ring system,
265	Oxygen atom other than as	206	e.g., camphoric acid, etc.
	Si-O-Si and at least one Si-C	286	Naphthenic acid or
	or Si-H group	005	derivative
266	Silicon containing SICP or	287	Aryl group
	solid polymer	288	Atom other than C, H, or O
	•	289	Sulfur

000		210	
290	\dots 0xygen atom other than as	310	\ldots OH group other than as
	part of a carboxylic acid or		part of a COOH group, e.g.,
	ester group		castor oil, etc.
291	OH group other than as	311	Three or more carboxylic
	part of a COOH group, e.g.,		acid ester groups
		312	
000	salicylic acid, etc.	_	Derived from glycerol
292	Carbonyl of a carboxylic	313	Fatty acid
	acid or ester group directly		triglyceride, e.g., drying
	attached to an aryl group,		oil, etc.
	e.g., dipropylene glycol	314	Ester derived from
	dibenzoate, etc.	311	dicarboxylic acid
293	Carboxylic acid or ester	215	
293		315	Carboxylic acid ester
	groups each directly attached	316	\ldots Atom other than C, H, or
	to separate aryl groups		0
	through the carbonyl of the	317	Oxygen atom other than as
	carboxylic acid or ester group		part of a carboxylic acid
294	Two or more carboxylic		
	acids or ester groups each		group, e.g., glycolic ester,
	directly attached to a nuclear		etc.
	-	318	Acyl group of the
	carbon of the same aryl group		carboxylic acid has at least
	through the carbonyl of the		fifteen carbon atoms, e.g.,
	carboxylic acid or ester group		butyl stearate, etc.
295	A single aryl group	319	Halogen
296	Only two carboxylic acid	320	_
	or ester groups directly	320	Oxygen atom other than as
	attached to an aryl group,		part of a COOH or derivative
			group
	e.g., phthalic acid, etc.	321	Two or more carboxylic
297	Dioctyl or dibutyl		acid or derivative groups
	ester, e.g., di-(2-ethylhexyl)	322	Acyl group of the
	phthalate, etc.	322	carboxylic acid or derivative
298	Three or more		has at least fifteen carbon
	carboxylic acid or ester		
	groups		atoms, e.g., stearic acid,
299			etc.
	Two or more aryl groups	323	\dots Aryl-OH or salt or aryl-O-
300	Two or more carbon atoms		metal bond DNRM
301	Metal	324	Fused or bridged ring
302	Sulfur, e.g., factice,		system
	etc.	325	_
303	Only two carboxylic acid	345	Fused or bridged ring
303			system having at least three
	or ester groups, e.g.,		rings
	distearyl thiodipropionate,	326	Cycloaliphatic group
	etc.	327	Metal
304	With a nonreactive	328	Group VIII metal (i.e.,
	material	320	Fe, Ru, Os, Co, Rh, Ir, Ni, Pd,
305	Nonreactive material		
	contains atom other than C, H,		Pt)
		329	Group IVA metal (i.e., Ge,
	or O		Sn, Pb)
306	Ester having at least two	330	Atom other than C, H, O, or
	carboxylic acid ester groups		halogen
307	Atom other than C, H, or	331	_
	0		Two or more sulfur atoms
300		332	S-S linkage
308	Oxygen atom other than as	333	Two or more separate aryl-
	part of a carboxylic acid		OH groups
	ester group	334	Oxygen other than as part
309	C.O. sussess at base there are	551	
	C=O group other than as		of an aryl-OH group
	part of COO group		of an aryl-OH group

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335	C=O group	360	Carbocyclic ring wherein
336	A single C=O group		one of the nuclear carbons
337	Aryl group having two or		thereof is double bonded
33.	more OH groups directly		directly to an oxygen atom so
	attached to nuclear carbons		as to form a C=O group
	thereof		therewith, e.g.,
220			cyclohexanone, etc.
338	Two or more aryl-OH	261	_
	groups	361	Only C, H, and oxygen atoms
339	C-O-C linkage	362	Ten or more carbon atoms
340	Aryl compound having only	363	Two or more C=O DNRM
	one aryl ring and having one		compounds
	or more OH groups directly	364	With water, hydrocarbon,
	attached to nuclear carbons of		halohydrocarbon, or organic
	the aryl		oxygen containing nonreactive
341	Halogen		material
342	Two or more separate aryl-	365	Solid polymer derived from
342		303	ethylenic reactants only
0.4.0	OH groups	266	
343	Only two aryl-OH groups	366	C-O-C compound DNRM
344	Aryl group other than as	367	Fused or bridged ring
	part of an aryl-OH		system or a cycloaliphatic
345	Polyhydric aryl-OH compound		group
346	1,3-dihydroxy, e.g.,	368	\ldots Atom other than C, H, O, or
	resorcinol, etc.		halogen
347	1,4-dihydroxy, e.g.,	369	Aryl group other than as
517			part of a phenoxy group
240	hydroquinone, etc.	370	Aryl-O-aryl
348	Two or more aryl-OH DNRM	371	
	compounds	_	Halogen
349	Three or more substituents	372	Two or more phenoxy groups
	on the aryl-OH compound	373	Halogen
350	With other nonreactive	374	At least two diverse
	material		halogen atoms
351	Two substituents on the	375	Phenoxy group
	aryl-OH compound	376	OH group, e.g., Cellosolve,
352	A single substituent on the		etc.
332	aryl-OH compound	377	Two or more OH groups
252		378	5 -
353	With nonreactive organic		Only C, H, and O atoms
	material	379	Carbon atom single bonded to
354	Aldehyde DNRM,i.e., C-(C=O)		an oxygen atom and wherein the
	H		carbon atom is not double
355	Aryl		bonded to a chalcogen atom
356	Ketone or ketene DNRM, i.e.,		DNRM, e.g., alcohols, etc.
	C(C=0)C or C=C=0	380	Halogen or ethylenic
357	Two or more C(C=0)C groups		unsaturation
358	Carbocyclic ring wherein	381	Non C-OH oxygen atom, or
330			element other than C, O, or H,
	at least two of the nuclear		e.g., tartaric acid metal
	carbons thereof are double		salt, etc.
	bonded directly to oxygens	201	
	atom so as to form two or more	382	Heavy metal
	C=O groups therewith, e.g.,	383	Carbocyclic ring
	quinone, etc.	384	Aryl group
359	Carbocyclic ring, e.g.,	385	Only a single -C-OH group
	benzophenone, etc.		and at least six carbon atoms
		386	At least two -OH groups
		387	At least four -OH groups,
			e.g., pentaerythritol, etc.
			.5., 1 1 ,

388	At least one solid polymer	411	With halogenated
	derived from ethylenic reactants only	412	nonreactant materialHalogen atom other than
389	Two or more compounds	410	Cl
	containing -OH groups, or with water NRM	413	Transition metal other than Group VIII DNRM (i.e., Sc, Ti,
390	With hydrocarbon or		Mn, Cu, Y, Zr, Tc, Hf, Re)
201	halogenated hydrocarbon NRM	414	Phosphorus atom DNRM
391	Solid polymer or SICP derived from at least one	415	Atom other than P, O, H, or a metal
	nonethylenic reactant	416	Ammonium phosphate
392	Organic chalcogen other than oxygen as DNRM	417	<pre>Phosphorus atom directly bonded to four oxygen atoms,</pre>
393	\ldots Atom other than S, C, H, or		e.g., phosphoric acid, etc.
	a metal	418	Sulfur atom DNRM
394	<pre>DNRM, e.g., metal stearate, etc.</pre>	419	<pre>Two or more sulfur atoms; or at least one atom other than S, O, H, or a metal</pre>
395	Atom other than C, O, H, or a metal	420	<pre>Devoid of an oxygen atom, e.g., sulfide, etc.</pre>
396	Carbocyclic group, e.g.,	421	At least one hydrogen atom
	aryl, etc.	422	Sulfuric acid
397	Ethylenic group; or at	423	Sulfate group, e.g.,
	least two (C=O)O groups bonded		calcium sulfate, etc.
	to each other directly or only	424	Carbon atom DNRM
	by carbon atoms	425	Calcium carbonate, e.g.,
398	Transition metal atom		limestone, marble, etc.
	(atomic no. 21-29, 39-47, 57-79)	426	Solid polymer derived from at least one diene monomer
399	Heavy metal or aluminum	427	
	(atomic no. 13, 30-33, 48-51, 80-83)	427	Solid polymer derived from unsaturated hydrocarbon monomer
400	Group IIA metal (Be, Mg,	428	Nitrogen atom DNRM
	Ca, Sr, Ba)	429	Nitrogen directly bonded to
401	Inorganic compound devoid of a silicon atom DNRM		an oxygen atom, e.g., nitric acid, etc.
402	Chalcogen atom other than	430	A single type of metal atom
403	sulfur or oxygen DNRMAt least one element of the		and only oxygen atoms DNRM, e.g., metal oxide, etc.
	lanthanide series (atomic	431	Transition metal atom
	no.57-71) or contains a noble		(i.e., Fe,Co,Ni)
	metal atom (i.e., Au, Ag, Hg, Pt, Pd, Ir, Rh, Ru, Os)DNRM	432	Group IIB metal atom (i.e., Zn or Cd)
404	Boron atom DNRM	433	Group IIA metal atom (i.e.,
405	Boron directly bonded to oxygen		Be, Mg, Ca, Sr, Ba)
406	Group VIB metal atom DNRM	434	Heavy metal atom DNRM
	(i.e., Cr, Mo, W)	435	Transition metal atom (i.e., Fe, Co, Ni)
407	Chromium	436	Group IIA metal DNRM (i.e.,
408	Group V metal atom DNRM		Be, Mg, Ca, Sr, Ba)
400	(i.e., V, Nb, Ta, As, Bi, Sb)	437	Aluminum DNRM
409	Antimony	438	Nonmetal compound DNRM
410	Atom other than Sb and	439	Elemental metal DNRM
	oxygen	440	Transition metal atom DNRM
		441	Aluminum DNRM

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442	Soil or inorganic silicon DNRM (other than silicon dioxide, glass, quartz, novaculite, or silicon dioxide type)	464	Mixing with chlorine- or bromine-containing organic compound hydrocarbon mixture or composition or product thereof DNRM
443	<pre>Atom other than Si, O, H, Al, Fe, or a Group IA or IIA metal atom DNRM, e.g., slag, mineral wool, etc.</pre>	465	<pre>Mixing with two or more chlorine- or bromine- containing organic compounds; or with a chlorine- or</pre>
444	Aluminum atom DNRM		bromine-containing organic
445	<pre>Clay, e.g., fullers earth, fire clay, etc.</pre>		compound other than carbon tetrachloride, chloroform, or
446	With water NRM		methylene chloride, and having
447	Kaolin or bentonite		numerical limitations other
448	<pre>Diatomite or diatomaceous earth, e.g., kieselguhr, infusorial earth, etc.</pre>		than amount, e.g., included herein, are m.p., b.p., m.w, structure, etc., or
449	Mica		composition or product
450	Metal atom other than		thereof, DNRM
130	aluminum, e.g., zeolites, etc.	466	Two or more chlorine-or
451	Talc (soapstone) DNRM		bromine-containing organic
452	Asbestos DNRM		compounds
453		467	Chlorine or bromine organic
433	Aldehyde-nitrogen SICP or		compound containing a bridged,
4 - 4	solid polymer thereof		fused, or cycloalphatic ring
454	SICP or solid polymer	468	Chlorine or bromine organic
455	thereof		compound containing ethylenic
455	Halogen containing polymer		unsaturation
456	Group IIA metal atom DNRM	469	Bromine-containing organic
457	Polymerizing an ethylenic		compound
	monomer in the presence of a	470	Chlorine-containing aromatic
	preformed SICP or solid		compound
	polymer and in the presence of	471	Aromatic compound containing
	a nonreactive material so as		two or more aromatic rings
	to form an aqueous dispersion,	472	Chlorine-containing wax
	latex, suspension, or emulsion	473	Organic compound containing
458	therewith; or product thereofPolymerizing in the presence	270	two or more chlorine atoms
430	of water and in the presence	474	Mixing two or more
	of a solid polymer derived from ethylenic reactants only		hydrocarbons; or a hydrocarbon other than benzene, toluene,
459	Solid polymer utilized contains vinyl alcohol units		or xylene per se and having numerical limitations other
460	Solid polymer utilized is derived from an unsaturated carboxylic acid or salt		than amount, e.g., included herein are m.p., b.p., viscosity, structure, m.w.,
461	Polymerizing in the presence		etc. or composition or product
101	of a solid polymer derived		thereof, DNRM
	from ethylenic reactants only	475	With water NRM
462		476	Two or more hydrocarbons
402	Mixing with fluorine- or	477	At least two solid
	iodine-containing organic		hydrocarbons
	compound or composition; or product thereof DNRM	478	At least one
463	-		microcrystalline wax
403	Contains two or more fluorine	479	Mixture contains three or
	or iodine organic compounds		more waxes

480	Mixture contains microcrystalline wax having specified melting point	498	Solid polymer or solid SICP derived from or reacted with protein or biologically active
481	Unsaturated hydrocarbon		polypeptide or product thereof
482	Unsaturated hydrocarbon contains a bridged or fused ring	499	Solid polymer derived from monomer from unsaturated petroleum hydrocarbon fraction
483	Unsaturated hydrocarbon contains plural unsaturation	500	or product thereofContaining two or more solid
484 485	Aromatic hydrocarbon Aromatic hydrocarbon contains a bridged or fused		polymers; solid polymer or SICP and a SICP, SPFI, or an ethylenic reactant or product
	ring	F 0 1	thereof
486	<pre>Aromatic hydrocarbon contains two or more aromatic rings</pre>	501	<pre>Producing an aqueous system by mixing two or more aqueous emulsions, suspensions,</pre>
487	Hydrocarbon wax		dispersions, or solutions, or
488	Microcrystalline wax		any of the above in admixture
489	Wax having melting point above 120 deg. F (49 deg. C)		with one another and wherein each individually contains a solid polymer or SICP
490	<pre>Hydrocarbon having a specified name, molecular weight or chain length</pre>	502	At least one solid polymer derived from ethylenic reactants only
491	<pre>Hydrocarbon having a specified viscosity</pre>	503	Polyvinyl alcohol or modified form thereof
492	Mixing inorganic silicon- containing material having color or numerical limitations	504	Solid graft or solid graft- type copolymer with other solid polymer, SICP, or SPFI
	other than amount, e.g., included herein are m.p., chemical composition, particle	505	Solid block or solid block- type copolymer with other solid polymer, SICP or SPFI
	<pre>size, surface area, etc., or composition or product thereof, DNRM</pre>	506	With solid polymer derived from at least one Si-H or Si-C
493	Inorganic silicon-containing material having specified dimensions		reactant wherein at least one of the reactants forming the solid polymer is saturated; or
494	Material contains glass		with SPFI or SICP derived from
495	<pre>Mixing with carbon, e.g., graphite, etc., having numerical limitations, other</pre>		<pre>a Si-H or Si-C reactant wherein at least one of the necessary reactants is saturated</pre>
	than amount, e.g., included herein are particle size, surface area, etc., or composition or product thereof, DNRM	507	With solid polymer derived from at least one -N=C=X (X is chalcogen) reactant wherein at least one of the reactants
496	Carbon particle having specified dimension		forming the solid polymer is saturated; or with SPFI or
497	Mixing with titanium dioxide material having numerical limitations other than amount, e.g., included herein are particle size, etc., composition or product thereof, DNRM		SICP derived from a -N=C=X reactant wherein at least one of the necessary reactants is saturated

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508	<pre>With solid polymer derived from at least one reactant wherein at least one of the reactants forming the solid</pre>	521	Solid polymer derived from a monomer containing an atom other than C, O, H, or chlorine
	polymer is a phenol or inorganic phenolate; or with SPFI or SICP derived from	522	<pre>Solid polymer derived from carboxylic acid-containing monomer</pre>
	phenol or inorganic phenolate wherein at least one of the	523	Solid polymer derived from carboxylic acid ester monomer
F00	necessary reactants is saturated	524	<pre>Ester derived from an unsaturated alcohol and a</pre>
509	With aldehyde or aldehyde- type reactant		saturated acid, e.g., vinyl acetate, etc.
510 511	<pre>Water DNRM containingEthylenic polymer derived from at least one reactant</pre>	525	Solid polymer derived from monomer containing two or more ethylenic groups
512	<pre>containing two or more ethylenic groupsWith solid polymer derived</pre>	526	<pre>Two or more polymers derived from reactant containing two or more</pre>
011	from at least one reactant wherein at least one of the	527	ethylenic groupsSolid polymer derived from
	reactants forming the solid polymer is an aldehyde or	528	chlorine-containing reactantSolid polymer derived from
	derivative; or with SPFI or SICP derived from an aldehyde	529	acyclic hydrocarbonSolid polymer derived from
	or derivative wherein at least one of the necessary reactants is saturated	029	ethylenic monomers only admixed with ethylenic monomer
513	With polycarboxylic acid or derivative and a polyol at	530	Ethylenic monomer contains a nitrogen heterocycle
	least one of which is saturated or with solid	531	Ethylenic monomer contains a chalcogen heterocycle
514	<pre>polymer thereofWith polycarboxylic acid or</pre>	532	Ethylenic monomer contains a fused or bridged ring system
	derivative and a polyamine, or with nitrogen containing carboxylic acid or derivative	533	<pre>Ethylenic monomer contains at least one carboxylic acid ester group</pre>
	reactant at least one of which is saturated or with solid	534	Ethylenic monomer contains at least two ethylenic groups
515	polymer thereofTwo or more solid polymers	535	Ethylenic monomer contains at least one atom which is
	derived from ethylenic reactants only	536	other than C, H, or OEthylenic monomer is an
516	Solid polymer derived from nitrogen heterocycle monomer	537	acyclic hydrocarbonSolid polymer or SICP derived
517	Solid polymer from oxygen heterocycle monomer	F20	from an -O-(C=0)O- or hal- (C=O)-O- containing reactant
518	Solid polymer derived from fused or bridged ring monomer	538	Solid polymer or SICP derived from at least one nitrogen-containing carboxylic acid or
519	Solid polymer derived from halogen-containing monomer other than vinyl or vinylidene		derivative reactant or from a carboxylic acid or derivative and a polyamine
520	<pre>chlorideFluorine-containing monomer</pre>	539	Solid polymer or SICP derived from at least one carboxylic acid or derivative reactant

540	Solid polymer or SICP derived from at least one phenol or inorganic phenolate reactant	560	From ester derived from at least one unsaturated carboxylic acid and a
541	Aldehyde or derivative reactant		saturated alcohol, e.g., methyl methacrylate, etc.
542	Solid polymer or SICP derived from at least one aldehyde or	561	Interpolymerized with diverse carboxylic acid ester
543	<pre>derivative or ketone reactantPolymer derived from ethylenic reactants only</pre>	562	<pre>Interpolymerized with hydrocarbon containing a single ethylenic group</pre>
544	From fluorine-containing monomer	563	From ester derived from ethylenically unsaturated
545	<pre>Fluorine-containing monomer contains F and C only or only F, C, and H</pre>		<pre>alcohol and saturated carboxylic acid, e.g., vinyl acetate, etc.</pre>
546	Four or more fluorine atoms	564	Interpolymerized with
547	<pre>From reactant-containing atom other than O, N, C, halogen,</pre>		diverse carboxylic acid ester or with carboxylic acid reactant
	or hydrogen	F.C.F.	
548	From heterocyclic monomer	565	From acrylonitrile or
549	Five-membered oxygen ring,	566	methacrylonitrile monomerInorganic nonreactive
	e.g., coumarone-indene, etc.	300	material
550	From acetylenic monomer	567	
551	From halogen-containing	507	From halogen-containing
	monomer containing three or	F.C.0	monomer
	more carbon atoms and wherein	568	Vinylidene chloride
	at least one halogen atom is	569	Plasticizer additive
	present in other than salt	570	From hydrocarbon monomer
	form	571	Conjugated diene hydrocarbon
552	Diene	F	monomer
553	From cycloaliphatic or fused or bridged ring monomer	572	Adding nonreactive material to chemically modified solid polymer
554	Cycloaliphatic, fused, or	573	
	bridged monomer contains at	5/3	Interpolymer of two or more diene monomers
	least two unsaturated groups	574	
555	From nitrogen-containing monomer other than acrylonitrile or	574	<pre>Interpolymer with at least one aliphatic hydrocarbon monomer, e.g., butyl rubber,</pre>
	methacrylonitrile		etc.
556	From carboxylic acid or ester thereof monomer	575	Interpolymer with at least one aromatic hydrocarbon
557	Polyvinyl alcohol or		monomer
	modified forms thereof	575.5	Natural rubber
558	<pre>Acid or ester contains an oxygen atom which is other than part of a free carboxyl</pre>	576	<pre>Adding nonreactive material to chemically modified solid polymer</pre>
	group or carboxylic acid ester group	577	From aromatic hydrocarbon monomer
559	Ester contains two or more	578	Interpolymer with at least
	ester groups or at least one		one aliphatic hydrocarbon
	carboxylic ester group and at		monomer
	least one free acid group; or	579	From hydrocarbon containing
	carboxylic acid contains two		four or more carbon atoms
	or more free carboxyl groups		

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580	Adding nonreactive material	607	Two or more carboxylic acids
	to solid polymer and		or derivatives, or two or more
	subsequently chemically		nitrogen containing compounds
	modifying the polymer or	608	Water DNRM containing
	product	609	From sulfur-containing
581	\ldots Solid polymer derived from		reactant
	ethylene	610	From reactant-containing atom
582	From propylene as sole		other than N, C, H, O, or
	reactant monomer		halogen
583	Organic NRM additive	611	From phenol reactant
584	Inorganic NRM additive	612	From at least one oxygen or
	other than water		nitrogen-containing reactant
585	From ethylene as sole	650	Inorganic water settable
	reactant monomer		material containing
586	Inorganic NRM additive	700	Preparation of intentional or
587	High density polymer		desired composition by
588	From silicon-containing		formation of a solid polymer
	reactant		(SP) or SICP in presence of a
589	From -N=C=X reactant or		designated nonreactant
	blocked N=C=X reactant (X is		material (DNRM) other than
	chalcogen)		solely water, hydrocarbon,
590	With reactant containing at		silicon dioxide, glass,
	least one C-OH, (C=O)-OH or -		titanium dioxide or elemental
	C-O-C- group		carbon, composition thereof;
591	Water DNRM		or process of treating or
592	From ketone or ketene reactant		composition thereof
593	From aldehyde or derivative	701	Boron-containing DNRM
	reactant	702	Cellular material derived from
594	With phenol or inorganic		biological source as DNRM
	phenolate		other than farinaceous flour
595	Containing reactant having		or cotton or diatomaceous
000	atom other than C, H, or O		earth
596	Water DNRM	703	Corncob, bark, or cork
597	Nitrogen-containing reactant	704	Protein or biologically active
598	Water DNRM		polypeptide as DNRM
599	From carboxylic acid or	705	Coal or bituminous material,
377	derivative reactant		extract or derivative thereof,
600	Carboxylic acid contains		oil shale, or fatty still
000	three or more acid groups or		residue thereof, as DNRM
	derivative thereof	706	P-containing DNRM
601	From dicarboxylic acid or	707	Nitrogen
001	derivative and at least one	708	Phosphorus bonded directly
	polyol; or from a diester of a		to nitrogen
	polycarboxylic acid as sole	709	Tri organo phosphine or
	reactant		phosphonium compound
602	Nitrogen-containing reactant	710	Organic compound having
603	Reactant contains atom other		phosphorus bonded directly to
003	than C, H, or O		oxygen or sulfur
604	At least one polyol	711	\ldots .Containing a metal atom DNRM
001	containing only two -C-OH	712	Containing halogen DNRM
	groups reactant	713	Containing phenol or
605	Derived from terephthalic		carboxylic acid or derivative
000	acid or derivative		DNRM
606	Nitrogen-containing reactant		
000	wrcrogen-concarning reactable		

714	N-containing organic compound excluding unsubstituted ammonium as sole nitrogen in DNRM	739	Plural separate aryl-OH or salt groups bonded through carbon or a chalcogen containing radical, e.g.,
715	N=N linkage, e.g., axo dyes,		bisphenol A, etc.
	etc.	740	Aryl-OH or salt compound
716	Carbohydrate or derivative,		having at least one chalcogen-
	e.g., nitrocellulose, etc.		containing substituent, e.g.,
717	Heterocyclic structure other	741	hydroxy anisole, etc.
	than per se N-alkyl	741	Aryl-OH or salt compound having two or more
718	pyrrolidoneHetero nitrogen		substituents
719	3	742	Elemental or organic sulfur
719	Containing hetero chalcogen DNRM	7 12	compound as DNRM
720	Plural hetero N, i.e., same	743	Sulfone, e.g., sulfolane,
720	or different ring		etc.
721	Containing aryl-OH or salt	744	DMSO with additional oxygen
	thereof DNRM		or halogen compound DNRM
722	Amine nitrogen directly	745	Sulfate, sulfonate ester,
	bonded to aromatic ring		sulfonic acid, or salt thereof
723	Sulfur, e.g., sulfonamides,	746	Halogenated
	etc.	747	Containing ether or hydroxyl
724	ROH or COOH, or salts		group DNRM
	thereof, e.g., alkanol amine	748	Containing COOH or salt
	or amino acid, etc.		thereof or ester thereof DNRM
725	Nitrile	750	Mercaptan, mercaptide, or
726	Formamide or N,N-dialkyl	DE 1	thioether, e.g., aryl-SH, etc.
	amide or N-alkyl pyrrolidone	751	Heterocyclic chalcogen
727	With metal-containing	750	compound as DNRM
F.O.O.	material DNRM	752	With organic chalcogen
728	(C=O)N		compound, hydrocarbon, or halogenated hydrocarbon DNRM
729	X(C=X)X wherein X is chalcogen	753	Carboxylic acid ester
730	DNRM, e.g., carbonate, etcSi-C, Si-H contains DNRM,	733	linkage, e.g., oxyalkylated
730	metal-C or metal-H bond or		sorbitan ester, etc.
	organic compound containing Si	754	Plural hetero oxygen
731	Diorgano siloxane contains	755	Ether compound DNRM, e.g.,
751	units of -((R)Si(R)-O-)* where		aryl ether, dimethylether,
	* is subscript two or more		etc.
732	Carbohydrate or derivative as	757	Mixture of ether compounds;
	DNRM		or only two ether oxygens
733	Cellulose or derivative,		bonded to a carbon atom, e.g.,
	e.g., cotton, paper pulp, etc.		formal, acetal, etc.
734	Starch or derivative,	758	Halogenated
	farinaceous flour or meal	759	Containing carboxylic acid or
735	Lignin, tannin, or derivative	760	derivative DNRM
	as DNRM	760	<pre>Carboxylic acid or derivative has two or more</pre>
736	Aryl-OH or salt thereof as		ether linkages
T20	DNRM	761	Containing hydroxyl group
738	Plural separate aryl-OH	, , ,	DNRM
	groups or polyhydric aryl-OH,	762	Two or more ether linkages
	or salts thereof: e.g., resorcinol, etc.	•	in the hydroxyl group bearing
	, 22-2-2-2, 230.		molecule

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763	Oxygen containing wax as DNRM,	788	Calcium, e.g., calcium
	e.g., carnauba, montan,	700	carbonate, etc.
	ceresin, bees wax, oxidized	789	Elemental silicon, soil, or
764	petroleum wax, etc.		inorganic silicon compound as
764	Natural resin or derivative as	700	DNRM
	DNRM, e.g., rosin, shellac,	790	With reactive coupling agent
	etc., excluding tall oil per	791	Alkali or alkali earth
D.C.E.	se		silicate
765	Alcohol compound as DNRM,	792	Halogenated hydrocarbon DNRM
	i.e., R-OH	793	Halogenated hydrocarbon
766	Two or more alcohols		contains ethylenic
767	With water NRM		unsaturation
768	With hydrocarbon or	794	With water NRM
	halogenated hydrocarbon NRM	795	\dots Fluorinated
769	Chalcogen other than as R-OH	796	Nitrogen, halogen, or
770	Ketone or aldehyde as DNRM		compounds thereof DNRM
771	With hydrocarbon or	797	Solid polymer or SICP derived
	halogenated hydrocarbon NRM		from protein or biologically
772	Carboxylic acid or		active polypeptide and
	derivative, e.g., acetoacetic		ethylenic monomer or SPFI
	acid or ester or salt thereof,	798	Solid polymer or SICP derived
	etc.		from natural resin or natural
773	Carboxylic acid or derivative		resin derivative and ethylenic
	not containing a heavy metal		monomer or SPFI, e.g.,
	atom as DNRM, e.g., anhydride,		shellac, rosin, etc.
	acyl halide, ester or salt,	799	Solid polymer or SICP derived
	etc.		from lignin or tannin and
774	Cycloaliphatic group, e.g.,		ethylenic monomer or SPFI
	dimer acids containing thirty	800	Preparation of intentional or
	six carbon atoms, tall oil,	000	desired composition by
	etc.		formation of solid polymer or
775	Aryl group		SICP in the presence of water
776	Solid polymer derived from		as a designated nonreactant
	ethylenic monomers only		material (DNRM), or products
777	Group IA, unsubstituted		thereof
, , ,	ammonium, or Group IIA salt	801	Process of preparing water-in-
778	Solid polymer or SICP	001	oil emulsion or dispersion, or
110	derived from at least one		product thereof
	nonethylenic monomer	802	Aqueous carboxyl-bearing solid
779	<u>-</u>	002	polymer or SICP composition
119	Elemental metal or metal		chemically treated with
	compound not containing		aziridine, mono 1,2-epoxide,
700	silicon DNRM		or cyclic sulfonium compound
780	Heavy metal	803	Polyvinyl alcohol or partially
781	Copper	003	hydrolyzed polyvinyl acetate
783	Group IV or Group IIB, i.e.,		or chemically modified forms
	Ge, Sn, Pb, Zr, Ti, Hf, Zn, Cd,		thereof
=0.	Hg	804	
784	Tin	004	Solid polymer derived from ethylenic monomers only
785	Group VIII, i.e., Fe, Ru,	005	
	Os, Co, Rh, Ir, Ni, Pd, Pt	805	Fluorine-containing monomer
786	Al	806	Silicon-containing monomer
787	Inorganic metal compound	807	Monomer-containing element
	having S, C, or N, e.g., KSCN,		other than C, H, O, N, S, Hal,
	etc.		or Group IA metal atom

808	Monomer contains nitrogen atom as part of a heterocyclic	835	Two or more halogenated hydrocarbon monomers
	ring	836	Hydrocarbon monomer only
809	Two or more nitrogen atoms	837	Solid polymer or SICP derived
	in a single ring		from Si-containing reactant
811	Monomer contains chalcogen	838	_
011	_		N-containing reactant
	atom as part of heterocyclic	839	Solid polymer or SICP derived
	ring		from $-N=C=X$ (X is chalcogen)
812	N-containing monomer other		containing reactant
	than: unsubstituted ammonium	840	N=C=X reactant has ionic
	as sole nitrogen, acrylamide,		group attached thereto, e.g.,
	methylol acrylamide,		carboxyl sulfonic, etc.
	acrylonitrile and the	841	Solid polymer or SICP derived
	corresponding methacryl	041	
	compounds or mixtures thereof		from a phenolic reactant
012	-	842	With carbohydrate reactant,
813	Nitrogen-carbon-oxygen bond		e.g., starch, cellulose, or
	containing monomer, e.g.,		sugar, etc.
	allyl isocyanate, etc.	843	Solid polymer or SICP derived
814	N-monomer contains S		from an aldehyde or aldehyde
815	Quaternary nitrogen-		derivative reactant
	containing monomer, e.g.,	844	
	tetramethyl ammonium, etc.	044	With carbohydrate reactant,
816	-		e.g., starch, cellulose, cork,
010	N-monomer contains		etc.
	carboxylic acid or salt	845	Solid polymer derived from a
	thereof		reactant which is a carboxylic
817	S-containing monomer		acid or derivative
818	Aldehyde or ketone containing	846	Polymer of an ethylenic
	monomer		reactant with a saturated
819	Hydrocarbon monomer with		reactant
017	carboxylic acid, salt, or	847	
	nonnitrogen containing	84/	Carbon, titanium dioxide,
	derivative monomer		glass, or silicon dioxide
000			having specified crystalline
820	With N monomer		form or numerical limitation
821	Hydrocarbon monomer		other than amount, e.g.,
	contains at least two		included herein are particle
	ethylenic groups		size, shape, etc., as DNRM
822	Two or more hydrocarbon	848	Hydrocarbon material other than
	monomers		solely a fused ring, or
823	Two or more monomers-		cycloaliphatic hydrocarbon,
023			benzene, toluene, or xylene or
	containing carboxylic acid or		
	derivative		mixtures thereof; said
824	Aromatic monomer		material or mixture of
825	With halogenated hydrocarbon		materials having specified
	monomer		numerical limitations other
827	N-containing monomer		than amount, e.g., included
828	With hydrocarbon monomer		herein are m.p., b.p.,
			viscosity, particle size,
829	Two or more N monomers		etc., as DNRM
831	With unsaturated carboxylic	849	Solid polymer from ethylenic
	acid or ester monomer	J 17	monomer only, said polymer
832	Monomer is carboxylic acid or		formed in the presence of a
	derivative		-
833	Two or more carboxylic acids	0=0	nonreactant material
-	or derivatives	850	N-containing monomer
834	Halogenated hydrocarbon	851	Halogen-containing monomer
0.5.4			
	monomer		

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852	Chalcogen atom containing	875	With two or more alcohol
	monomer other than ether		hydroxyl compounds
	oxygen as sole chalcogen	876	Phenolic reactant forming a
853	Carboxylic acid or derivative		solid polymer or SICP in the
	monomer		presence of a nonreactant
854	Monomer containing at least		material
	two carboxylic acid or	877	Aldehyde or derivative or
	derivative groups		ketone as reactant forming a
855	From unsaturated hydrocarbon		solid polymer or SICP in the
	monomer solely		presence of a nonreactant
856	Contains two or more		material
	ethylenic unsaturated groups	878	Carboxylic acid or derivative,
857	Boron or metal-containing		excluding nitrile as sole
	reactant forming a solid		derivative as reactant forming
	polymer or SICP in the		a solid polymer in the
	presence of a nonreactant		presence of a nonreactant
	material		material or mixture of
858	Si-containing reactant forming		materials having specified
	a solid polymer or SICP in the		numerical limitations other
	presence of a nonreactant	0.77.0	than
	material	879	Nitrogen-containing reactant
859	Silicate containing compound	881	Ethylenically unsaturated
	as sole Si-containing		compound, or compound
	reactant, e.g., ortho silicate		containing element other than
	esters, etc.		C, H, O, or N (e.g., P, S,
860	Poly (di organo siloxane)		etc.) as reactant forming a
	reactant, i.e., $(R-Si(R)-0)-*$		solid polymer in the presence
	where R is an organic radical		of an NRM
	and * is subscript two or more		
861	Si-H containing reactant		
861 862	Si-H containing reactantWith ethylenically		
862	<pre>Si-H containing reactantWith ethylenically unsaturated reactant</pre>	CROSS-I	REFERENCE ART COLLECTIONS
	<pre>Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane)</pre>		_
862	<pre>Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO</pre>	900	ANTIGEN-ANTIBODY
862	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g.,	900 901	_
862 863	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etc.	900 901 902	ANTIGEN-ANTIBODY
862 863 864	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactant	900 901 902 903	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS
862 863	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated	900 901 902 903 904	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray
862 863 864 865	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactant	900 901 902 903	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS
862 863 864	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated	900 901 902 903 904	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS
862 863 864 865 866	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactant	900 901 902 903 904 905	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS
862 863 864 865 866 868	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactant	900 901 902 903 904 905 906	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS
862 863 864 865 866 868 869	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactant	900 901 902 903 904 905 906	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER
862 863 864 865 866 868	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant	900 901 902 903 904 905 906	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR
862 863 864 865 866 868 869	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantHeterocyclic reactantN-containing reactant .N-C=X containing reactant forming a solid polymer or	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER
862 863 864 865 866 868 869	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant forming a solid polymer or SICP in the presence of a	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED
862 863 864 865 866 868 869	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR
862 863 864 865 866 868 869 871	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is chalcogen)	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR BALL, ETC., AND OTHER THAN
862 863 864 865 866 868 869	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is chalcogen)Two or more N=C=X containing	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR BALL, ETC., AND OTHER THAN SHEET, FILM, OR FIBER REVERSE OSMOSIS MEMBRANE COMPOSITIONS, E.G.,
862 863 864 865 866 868 869 871	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is chalcogen)Two or more N=C=X containing reactants (other than	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR BALL, ETC., AND OTHER THAN SHEET, FILM, OR FIBER REVERSE OSMOSIS MEMBRANE COMPOSITIONS, E.G., DESALINIZATION, ETC.
862 863 864 865 866 868 869 871	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is chalcogen)Two or more N=C=X containing reactants (other than conventional isomer mixtures)	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR BALL, ETC., AND OTHER THAN SHEET, FILM, OR FIBER REVERSE OSMOSIS MEMBRANE COMPOSITIONS, E.G., DESALINIZATION, ETC. ANTISTATIC COMPOSITIONS
862 863 864 865 866 868 869 871	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is chalcogen)Two or more N=C=X containing reactants (other than conventional isomer mixtures)Aliphatic or cycloaliphatic	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR BALL, ETC., AND OTHER THAN SHEET, FILM, OR FIBER REVERSE OSMOSIS MEMBRANE COMPOSITIONS, E.G., DESALINIZATION, ETC. ANTISTATIC COMPOSITIONS .Composition to apply to a
862 863 864 865 866 868 869 871	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is chalcogen)Two or more N=C=X containing reactants (other than conventional isomer mixtures)Aliphatic or cycloaliphatic N=C=X compound	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR BALL, ETC., AND OTHER THAN SHEET, FILM, OR FIBER REVERSE OSMOSIS MEMBRANE COMPOSITIONS, E.G., DESALINIZATION, ETC. ANTISTATIC COMPOSITIONS .Composition to apply to a substrate to be destaticized
862 863 864 865 866 868 869 871	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is chalcogen)Two or more N=C=X containing reactants (other than conventional isomer mixtures)Aliphatic or cycloaliphatic	900 901 902 903 904 905 906 907	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR BALL, ETC., AND OTHER THAN SHEET, FILM, OR FIBER REVERSE OSMOSIS MEMBRANE COMPOSITIONS, E.G., DESALINIZATION, ETC. ANTISTATIC COMPOSITIONS .Composition to apply to a substrate to be destaticized .Contains metal, boron,
862 863 864 865 866 868 869 871	Si-H containing reactantWith ethylenically unsaturated reactantPoly (di organo siloxane) reactant has at least one SiO other than as Si-O Si, e.g., Si-O-C, or SiOH group, etcWith N-containing reactantWith ethylenic unsaturated reactantEthylenically unsaturated reactantHeterocyclic reactantN-containing reactantN-C=X containing reactant forming a solid polymer or SICP in the presence of a nonreactant material (X is chalcogen)Two or more N=C=X containing reactants (other than conventional isomer mixtures)Aliphatic or cycloaliphatic N=C=X compound	900 901 902 903 904 905 906 907 908	ANTIGEN-ANTIBODY ELECTRODEPOSITABLE COMPOSITIONS .Electrostatic spray AEROSOL COMPOSITIONS POWDER COATING COMPOSITIONS ETCH MASKING COMPOSITIONS MULTIPACKAGE COMPOSITIONS ADDITIVE OF SPECIFIED SHAPE OTHER THAN FIBER, PARTICLE, OR POWDER COMPOSITION HAVING SPECIFIED SHAPE, E.G., ROD, STICK, OR BALL, ETC., AND OTHER THAN SHEET, FILM, OR FIBER REVERSE OSMOSIS MEMBRANE COMPOSITIONS, E.G., DESALINIZATION, ETC. ANTISTATIC COMPOSITIONS .Composition to apply to a substrate to be destaticized

913	.Contains nitrogen nonreactant
014	material
914	FLOOR COVERING COMPOSITIONS
915	CARPET BACKING ADHESIVES
916	HYDROGEL COMPOSITIONS
917	OIL SPILL RECOVERY COMPOSITIONS
918	WOOD PATCHING COMPOSITION
919	METAL PATCHING COMPOSITION, E.G.,
	BODY SOLDER, ETC.
920	COILABLE PIPE COMPOSITIONS
921	ELASTIC MEMORY OR HEAT SHRINKABLE
	COMPOSITIONS
922	FLOCCULATING, CLARIFYING, OR
	FINING COMPOSITIONS
923	TREATING OR PREPARING A
	NONAQUEOUS DISPERSION OR
	EMULSION OF A SOLID POLYMER OR
	SPECIFIED INTERMEDIATE
	CONDENSATION PRODUCT
924	TREATING OR PREPARING A
	NONAQUEOUS SOLUTION OF A SOLID
	POLYMER OR SPECIFIED
	INTERMEDIATE CONDENSATION
	PRODUCT
925	NATURAL RUBBER COMPOSITIONS
	HAVING NONREACTIVE MATERIALS
	(DNRM) OTHER THAN: CARBON,
	SILICON DIOXIDE, GLASS
	TITANIUM DIOXIDE, WATER,
	HYDROCARBON, HALOHYDROCARBON
926	.With water as NRM, exemplified
927	Before 1930
928	.Before 1930, exemplified
929	.Natural rubber broadly
	disclosed, nonclaimed

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